

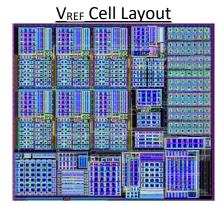
VREF1 (internal #chip1_VREF2)

Ultra-Low-Power Bandgap Voltage Reference with low TC. Proof of silicon with typical/preliminary measurements available.

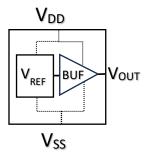
Please contact sales@ailinear.com for more information & order specific evaluation

Parameter	Typical	Condition
	Spec	
I _{DD} (nA)	~153	V _{DD} =2v, Temperature = 27C
V _{DD} Low (v)	~1.5	V_{DD} sweep $0v\rightarrow 2.2v$, Temperature = 27C
V _{DD} High (v)	~2	V_{DD} sweep $0v\rightarrow 2.2v$, Temperature = 27C
VREF _{OUT} (v)	~1.28	V _{DD} =2v, Temperature = 27C
TC (PPM/C)	~150	V _{DD} =2v, ΔT ~30C
PSRR (dB)	~68	V_{DD} sweep 1v \rightarrow 2.2v, Temperature = 27C

See Disclaimer



V_{REF} Block Diagram



V_{REF} Cell Size ~180μm×150 μm in TSMC 180nm CMOS

Features:

- Small CMOS (~180 μ m×150 μ m) bandgap voltage reference (V_{OUT} \approx V_{REF} \approx V_{BG} \approx 1.28) Intellectual Property (IP) cell operates in subthreshold with ultra-low I_{DD} (typical 153nA)
- Patented Low noise design to generate proportional to absolute voltage (V_{PTAT}) without resistors
- Equipped with start-up, power-down, and TC trim capability
- Includes an internal buffer (BUF) to drive larger loads (e.g. Mega Ω s) in a SoC
- No clock, no switch-capacitor, and no related noise or injections into substrate
- Operating in subthreshold and requiring no resistors facilitate small silicon area and operations at ultra-low currents
- Operation at low V_{DD} levels ≈V_{REF} + 2V_{DS}
- Utilizes parasitic (substrate) bipolar junction transistor (BJT) freely available in digital CMOS
- Manufacturable on trailing-to-bleeding edge digital CMOS
- Based on 180nm digital CMOS at TSMC and portable to smaller fabrication nodes.